

EAST Search History

EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L3	1	(US-6628355-\$).did.	USPAT	OR	OFF	2009/09/24 12:31
L4	1	3 and (etch\$5 remov\$4 mask\$4 photo laser\$2 uv chemical cur\$4 radiat\$4) same (lens\$2 microlens\$4)	USPAT	OR	OFF	2009/09/24 12:32
L5	1	3 and (etch\$5 remov\$4 mask\$4 photo laser\$2 uv chemical cur\$4 radiat\$4 ultraviolet rays irradiat\$4) same (lens\$2 microlens\$4)	USPAT	OR	OFF	2009/09/24 12:34
L6	1	3 and (etch\$5 remov\$4 mask\$4 photo laser\$2 uv chemical cur\$4 radiat\$4 ultraviolet rays irradiat\$4) same (lens\$2 microlens\$4) and panel and (etch\$5 remov\$4 mask\$4 photo laser\$2 uv chemical cur\$4 radiat\$4 ultraviolet rays irradiat\$4) same panel	USPAT	OR	OFF	2009/09/24 12:44
L7	1	3 and (etch\$5 remov\$4 mask\$4 photo laser\$2 uv chemical cur\$4 radiat\$4 ultraviolet rays irradiat\$4) same (lens\$2 microlens\$4) and panel and (etch\$5 remov\$4 mask\$4 photo laser\$2 uv chemical cur\$4 radiat\$4 ultraviolet rays irradiat\$4) same panel same (lens\$2 microlens\$4)	USPAT	OR	OFF	2009/09/24 12:46
L8	1	3 and (microlens\$4) near12 (form\$4 process\$4 form\$4)	USPAT	OR	OFF	2009/09/24 13:45
L9	1	3 and (microlens\$4) near12 (form\$4 process\$4 form\$4 fabricat\$5)	USPAT	OR	OFF	2009/09/24 13:46

L10	117	(expos\$4 near7 (beam\$4 light radiat\$4 laser ld\$1 laser\$1 ld\$3) Lithography photolithography photosensitive irradiat\$4 radiat\$4 photocur\$4 photosensitiv\$2) same (lens\$3 microlens\$4) same (layer material) and (form\$4 creat\$4 produc\$4 construct\$4 ceat\$4) near5 (microlens\$2 micro adj1 lens\$2) and display same pixel\$2 and (display\$4 pixel\$2) same (pictur\$2 near3 elements color\$3 colour\$3 blue green RGB R near7 (g b)) and (display\$4 pixel\$2) same (color\$3 colour\$3 blue green RGB R near7 (g b)) and display adj1 panel\$1	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2009/09/24 14:26
S1	1	10/582172	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/06 17:26
S2	45993	"349"/\$.cds.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/06 17:43
S3	428	"349"/95.cds.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/06 17:44
S4	291	S3 and (microlens\$2 micro adj1 lens\$2)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/06 17:44
S5	217	S3 and (form\$4 creat\$4 produc\$4 construct\$4 ceat\$4) near5 (microlens\$2 micro adj1 lens\$2)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/06 17:47
S6	1	S1 and (expos\$4 laser\$1 ld\$3 photo\$6 Lithography photolithography photosensitive) same (lens\$3 microlens\$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/06 17:51

S7	123	S5 and (expos\$4 near7 (beam\$4 light radiat\$4 laser ld\$1) laser\$1 ld\$3 Lithography photolithography photosensitive irradiat\$4 radiat\$4 photocur\$4) same (lens\$3 microlens \$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/06 17:57
S8	789	(expos\$4 near7 (beam \$4 light radiat\$4 laser ld \$1) laser\$1 ld\$3 Lithography photolithography photosensitive irradiat\$4 radiat\$4 photocur\$4) same (lens\$3 microlens \$4) and (form\$4 creat \$4 produc\$4 construct \$4 ceat\$4) near5 (microlens\$2 micro adj1 lens\$2) and display same pixel\$2 and (display\$4 pixel\$2) same (color\$3 colour\$3 blue green RGB R near7 (g b))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/06 18:32
S9	795	(expos\$4 near7 (beam \$4 light radiat\$4 laser ld \$1) laser\$1 ld\$3 Lithography photolithography photosensitive irradiat\$4 radiat\$4 photocur\$4) same (lens\$3 microlens \$4) and (form\$4 creat \$4 produc\$4 construct \$4 ceat\$4) near5 (microlens\$2 micro adj1 lens\$2) and display same pixel\$2 and (display\$4 pixel\$2) same (pictur\$2 near3 elements color\$3 colour \$3 blue green RGB R near7 (g b))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/06 18:33

S10	789	S9 and (expos\$4 near7 (beam\$4 light radiat\$4 laser ld\$1) laser\$1 ld\$3 Lithography photolithography photosensitive irradiat\$4 radiat\$4 photocur\$4) same (lens\$3 microlens \$4) and (form\$4 creat \$4 produc\$4 construct \$4 ceat\$4) near5 (microlens\$2 micro adj1 lens\$2) and display same pixel\$2 and (display\$4 pixel\$2) same (pictur\$2 near3 elements color\$3 colour \$3 blue green RGB R near7 (g b)) and (display\$4 pixel\$2) same (color\$3 colour\$3 blue green RGB R near7 (g b))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/06 18:35
S11	659	(expos\$4 near7 (beam \$4 light radiat\$4 laser ld \$1 laser\$1 ld\$3) Lithography photolithography photosensitive irradiat\$4 radiat\$4 photocur\$4 phtosensitiv\$2) same (lens\$3 microlens\$4) and (form\$4 creat\$4 produc\$4 construct\$4 ceat\$4) near5 (microlens \$2 micro adj1 lens\$2) and display same pixel \$2 and (display\$4 pixel \$2) same (pictur\$2 near3 elements color\$3 colour\$3 blue green RGB R near7 (g b)) and (display\$4 pixel\$2) same (color\$3 colour\$3 blue green RGB R near7 (g b))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/06 20:51

S12	175	(expos\$4 near7 (beam \$4 light radiat\$4 laser ld \$1 laser\$1 ld\$3) Lithography photolithography photosensitive irradiat\$4 radiat\$4 photocur\$4 photosensitiv\$2) same (lens\$3 microlens\$4) and (form\$4 creat\$4 produc\$4 construct\$4 coat\$4) near5 (microlens \$2 micro adj1 lens\$2) and display same pixel \$2 and (display\$4 pixel \$2) same (pictur\$2 near3 elements color\$3 colour\$3 blue green RGB R near7 (g b)) and (display\$4 pixel\$2) same (color\$3 colour\$3 blue green RGB R near7 (g b)) and display adj1 panel\$1	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/06 20:56
S13	103	(expos\$4 near7 (beam \$4 light radiat\$4 laser ld \$1 laser\$1 ld\$3) Lithography photolithography photosensitive irradiat\$4 radiat\$4 photocur\$4 photosensitiv\$2) same (lens\$3 microlens\$4) same (layer material) and (form\$4 creat\$4 produc\$4 construct\$4 coat\$4) near5 (microlens \$2 micro adj1 lens\$2) and display same pixel \$2 and (display\$4 pixel \$2) same (pictur\$2 near3 elements color\$3 colour\$3 blue green RGB R near7 (g b)) and (display\$4 pixel\$2) same (color\$3 colour\$3 blue green RGB R near7 (g b)) and display adj1 panel\$1	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/06 20:58
S14	1	S1 and (mask\$4 remov \$4 etch\$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/06 21:00

S15	48	S13 and (mask\$4 etch\$4 remov\$4) same (microlens\$2 micro adj1 lens\$2) and pixels	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/06 21:06
S16	103	(expos\$4 near7 (beam\$4 light radiat\$4 laser ld\$1 laser\$1 ld\$3) Lithography photolithography photosensitive irradiat\$4 radiat\$4 photocur\$4 photosensitiv\$2) same (lens\$3 microlens\$4) same (layer material) and (form\$4 creat\$4 produc\$4 construct\$4 ceat\$4) near5 (microlens\$2 micro adj1 lens\$2) and display same pixel\$2 and (display\$4 pixel\$2) same (pictur\$2 near3 elements color\$3 colour\$3 blue green RGB R near7 (g b)) and (display\$4 pixel\$2) same (color\$3 colour\$3 blue green RGB R near7 (g b)) and display adj1 panel\$1	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 11:19
S17	48	S16 and (mask\$4 etch\$4 remov\$4) same (microlens\$2 micro adj1 lens\$2) and pixels	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 11:19
S18	49	S16 and (photomask\$4 mask\$4 etch\$4 remov\$4) same (microlens\$2 micro adj1 lens\$2) and pixels	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 11:23
S19	1	10/582172	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 11:28
S20	1	S19 and (photomask\$4 mask\$4 etch\$4 remov\$4) same (microlens\$2 micro adj1 lens\$2) same pixels	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 11:28
S21	1	S19 and (photomask\$4 mask\$4 etch\$4 remov\$4) same (microlens\$2 micro adj1 lens\$2) and pixels	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 11:36

S22	1	S19 and (photomask\$4 mask\$4 etch\$4 remov \$4) same (microlens\$2 micro adj1 lens\$2 color \$2 colour\$2 elements) and pixels	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 11:37
S23	1	S19 and (photomask\$4 mask\$4 etch\$4 remov \$4) same (microlens\$2 micro adj1 lens\$2 r near7 g blue) same (color\$2 colour\$2 elements pixel\$1)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 11:38
S24	1	S19 and (photomask\$4 mask\$4 etch\$4 remov \$4) same (microlens\$2 micro adj1 lens\$2 r near7 g blue) same (color\$2 colour\$2 elements pixel\$1) and (apertures windows slits holes)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 11:41
S25	1	S19 and (pictur\$2 near3 elements) near5 pixel\$2	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 11:45
S26	58	S16 and (pictur\$2 near3 elements magenta c near6 y r near6 g green) near12 pixel\$2	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 11:52
S27	35	S26 and (photomask\$4 mask\$4 etch\$4 remov \$4 apertures windows slits holes) same (microlens\$2 micro adj1 lens\$2) and pixels	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 11:53
S28	39	S16 and (pictur\$2 near3 elements magenta c near6 y r near6 g green color\$1 colour\$1) near12 pixel\$2 and (lens \$2 microlens\$2) near12 (pictur\$2 near3 elements magenta c near6 y r near6 g green color\$1 colour\$1) and wavelength\$1	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 12:04
S29	25	S28 and (photomask\$4 mask\$4 etch\$4 remov \$4 apertures windows slits holes) same (microlens\$2 micro adj1 lens\$2) and pixels	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 12:06

S31	15	S16 and filter\$4 near12 microlens\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 12:30
S32	1	S19 and filter\$4 near12 microlens\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 12:30
S33	8	S29 and filter\$4 near12 microlens\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 12:31
S34	7	(US-20070216827-\$ or US-20050068475-\$ or US-20040263670-\$ or US-20020131022-\$). did. or (US-6939008-\$ or US-6628355-\$ or US-6219113-\$).did.	US-PGPUB; USPAT	OR	OFF	2008/05/07 12:32
S35	1	S19 and (material\$2 photocur\$4) same (opposit\$2 fac\$2 surfac \$4 substrat\$2 pair)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 12:38
S36	1	S19 and (material\$2 photocur\$4) same (opposit\$2 fac\$2 surfac \$4 substrat\$2 pair)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 12:38
S37	1	10/582172	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 13:49
S38	1	S37 and (material\$2 photocur\$4) same (opposit\$2 fac\$2 surfac \$4 substrat\$2 pair)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 13:49
S39	7	(US-20070216827-\$ or US-20050068475-\$ or US-20040263670-\$ or US-20020131022-\$). did. or (US-6939008-\$ or US-6628355-\$ or US-6219113-\$).did.	US-PGPUB; USPAT	OR	OFF	2008/05/07 13:49
S40	103	(expos\$4 near7 (beam \$4 light radiat\$4 laser ld \$1 laser\$1 ld\$3) Lithography photolithography photosensitive irradiat\$4 radiat\$4 photocur\$4 photosensitiv\$2) same (lens\$3 microlens\$4) same (layer material) and (form\$4 creat\$4 produc\$4 construct\$4 ceat\$4) near5 (microlens \$2 micro adj1 lens\$2)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 13:49

		and display same pixel \$2 and (display\$4 pixel \$2) same (pictur\$2 near\$3 elements color\$3 colour\$3 blue green RGB R near7 (g b)) and (display\$4 pixel\$2) same (color\$3 colour\$3 blue green RGB R near7 (g b)) and display adj1 panel\$1				
S41	39	S40 and (pictur\$2 near\$3 elements magenta c near6 y r near6 g green color\$1 colour\$1) near12 pixel\$2 and (lens\$2 microlens\$2) near12 (pictur\$2 near\$3 elements magenta c near6 y r near6 g green color\$1 colour\$1) and wavelength\$1	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 13:49
S42	25	S41 and (photomask\$4 mask\$4 etch\$4 remov \$4 apertures windows slits holes) same (microlens\$2 micro adj1 lens\$2) and pixels	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 13:49
S43	8	S42 and filter\$4 near12 microlens\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 13:49
S44	373367	((expos\$4 near7 (beam \$4 light radiat\$4 laser ld \$1 laser\$1 ld\$3) Lithography photolithography photosensitive irradiat\$4 radiat\$4 photocur\$4 photosensitiv\$2) (microlens\$2 lens\$2)) same substrat\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 14:00
S45	7	S39 and S44	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 14:01

S46	36	S40 and (pictur\$2 near3 elements magenta c near6 y r near6 g green color\$1 colour\$1) same pixel\$2 and (lens\$2 microlens\$2) same (pictur\$2 near3 elements magenta c near6 y r near6 g green color\$1 colour\$1) and wavelength\$1 and (photomask\$4 mask\$4 etch\$4 remov\$4 apertures windows slits holes) same (microlens \$2 micro adj1 lens\$2) and pixels	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 14:11
S47	30	S46 and filter\$4 same (lens\$2 microlens\$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 14:13
S48	22	S47 not S43	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 14:13
S49	4	(US-20050253975-\$ or US-20040240777-\$ or US-20040114111-\$). did. or (US-5550656-\$). did.	US-PGPUB; USPAT	OR	OFF	2008/05/07 14:22
S50	2	(US-20020131022-\$). did. or (US-6628355-\$). did.	US-PGPUB; USPAT	OR	OFF	2008/05/07 14:22
S51	6	S49 S50	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 14:22
S53	6	S51 and (dispal\$3 substrate\$2) same (lens \$2 microlens\$2)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 14:34
S54	6	S51 and (form\$4 creat \$4 produc\$4 construct \$4 ceat\$4) near8 (microlens\$2 micro adj1 lens\$2)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 14:44
S55	4	(US-20050253975-\$ or US-20040240777-\$ or US-20040114111-\$). did. or (US-5550656-\$). did.	US-PGPUB; USPAT	OR	OFF	2008/05/07 16:14
S56	2	(US-20020131022-\$). did. or (US-6628355-\$). did.	US-PGPUB; USPAT	OR	OFF	2008/05/07 16:14

S57	6	S55 S56	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 16:14
S58	6	S57 and (form\$4 creat \$4 produc\$4 construct \$4 ceat\$4) near8 (microlens\$2 micro adj1 lens\$2)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 16:14
S59	6	S57 and (expos\$4 near7 (beam\$4 light radiat\$4 laser ld\$1 laser \$1 ld\$3) Lithography photolithography photosesitive irradiat\$4 radiat\$4 photocur\$4 photosensitiv\$2) same (lens\$3 microlens\$4) same (layer material)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 16:24
S60	5	S59 and (etch\$4 remov \$4) same (lens\$3 microlens\$4 layer material)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 16:34
S61	2	S60 and (etch\$4 remov \$4 expos\$4 near7 (beam \$4 light radiat\$4 laser ld \$1 laser\$1 ld\$3) Lithography photolithography photosesitive irradiat\$4 radiat\$4 photocur\$4 photosensitiv\$2) same (pictur\$2 near3 elements color\$3 colour \$3 blue green RGB R near7 (g b))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 16:44
S62	5	S60 and (etch\$4 remov \$4 expos\$4 near7 (beam \$4 light radiat\$4 laser ld \$1 laser\$1 ld\$3) Lithography photolithography photosesitive photo\$7 \$8graphy irradiat\$4 radiat\$4 photocur\$4 photosensitiv\$2) same (pictur\$2 near3 elements color\$3 colour \$3 blue green RGB R near7 (g b) pixel\$2)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 16:48

S63	4	(US-20050253975-\$ or US-20040240777-\$ or US-20040114111-\$). did. or (US-5550656-\$). did.	US-PGPUB; USPAT	OR	OFF	2008/05/07 19:43
S64	2	(US-20020131022-\$). did. or (US-6628355-\$). did.	US-PGPUB; USPAT	OR	OFF	2008/05/07 19:43
S65	6	S63 S64	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 19:43
S66	6	S65 and (expos\$4 near7 (beam\$4 light radiat\$4 laser ld\$1 laser \$1 ld\$3) Lithography photolithography photosesitive irradiat\$4 radiat\$4 photocur\$4 phtosensitiv\$2) same (lens\$3 microlens\$4) same (layer material)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 19:43
S67	5	S66 and (etch\$4 remov \$4) same (lens\$3 microlens\$4 layer material)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 19:43
S68	5	S67 and (etch\$4 remov \$4 expos\$4 near7 (beam \$4 light radiat\$4 laser ld \$1 laser\$1 ld\$3) Lithography photolithography photosesitive photo\$7 \$8graphy irradiat\$4 radiat\$4 photocur\$4 phtosensitiv\$2) same (pictur\$2 near3 elements color\$3 colour \$3 blue green RGB R near7 (g b) pixel\$2)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 19:43
S69	2	(US-20020131022-\$). did. or (US-6628355-\$). did.	US-PGPUB; USPAT	OR	OFF	2008/05/07 20:36
S70	1	(US-20020131022-\$). did.	US-PGPUB	OR	OFF	2008/05/07 20:36
S71	0	S70 and mask\$4 near12 (pictur\$2 near3 elements color\$3 colour \$3 blue green RGB R near7 (g b) pixel\$2)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 20:38

S72	0	S70 and mask\$4 same (pictur\$2 near\$3 elements color\$3 colour\$3 blue green RGB R near\$7 (g b) pixel\$2 aperture\$2 window\$2 slits)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 20:40
S73	103	(expos\$4 near\$7 (beam\$4 light radiat\$4 laser ld\$1 laser\$1 ld\$3) Lithography photolithography photosensitive irradiat\$4 radiat\$4 photocur\$4 photosensitiv\$2) same (lens\$3 microlens\$4) same (layer material) and (form\$4 creat\$4 produc\$4 construct\$4 coat\$4) near\$5 (microlens\$2 micro adj1 lens\$2) and display same pixel\$2 and (display\$4 pixel\$2) same (pictur\$2 near\$3 elements color\$3 colour\$3 blue green RGB R near\$7 (g b)) and (display\$4 pixel\$2) same (color\$3 colour\$3 blue green RGB R near\$7 (g b)) and display adj1 panel\$1	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 20:43
S74	36	S73 and (pictur\$2 near\$3 elements magenta c near\$6 y r near\$6 g green color\$1 colour\$1) same pixel\$2 and (lens\$2 microlens\$2) same (pictur\$2 near\$3 elements magenta c near\$6 y r near\$6 g green color\$1 colour\$1) and wavelength\$1 and (photomask\$4 mask\$4 etch\$4 remov\$4 apertures windows slits holes) same (microlens\$2 micro adj1 lens\$2) and pixels	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 20:43
S75	30	S74 and filter\$4 same (lens\$2 microlens\$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 20:43

S76	6	S74 not S75	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 20:43
S77	6	(US-20080018558-\$ or US-20070171493-\$ or US-20040125048-\$ or US-20020020832-\$). did. or (US-7321349-\$ or US-5835458-\$).did.	US-PGPUB; USPAT	OR	OFF	2008/05/07 20:45
S78	5	S77 and (etch\$4 remov \$4 expos\$4 near7 (beam \$4 light radiat\$4 laser ld \$1 laser\$1 ld\$3) Lithography photolithography photosensitive photo\$7 \$8graphy irradiat\$4 radiat\$4 photocur\$4 photosensitiv\$2) same (pictur\$2 near3 elements color\$3 colour \$3 blue green RGB R near7 (g b) pixel\$2)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 20:47
S79	1	(US-20040125048-\$). did.	US-PGPUB	OR	OFF	2008/05/07 20:49
S80	2	S69 and (etch\$4 remov \$4 expos\$4 near7 (beam \$4 light radiat\$4 laser ld \$1 laser\$1 ld\$3) Lithography photolithography photosensitive photo\$7 \$8graphy irradiat\$4 radiat\$4 photocur\$4 photosensitiv\$2) same (pictur\$2 near3 elements color\$3 colour \$3 blue green RGB R near7 (g b) pixel\$2)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 20:50
S81	1	S79 and (etch\$4 remov \$4 expos\$4 near7 (beam \$4 light radiat\$4 laser ld \$1 laser\$1 ld\$3) Lithography photolithography photosensitive photo\$7 \$8graphy irradiat\$4 radiat\$4 photocur\$4 photosensitiv\$2) same (pictur\$2 near3 elements color\$3 colour \$3 blue green RGB R near7 (g b) pixel\$2)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/07 20:50

S82	1	(US-6628355-\$). did.	USPAT	OR	OFF	2008/05/08 13:29
S83	1	S82 and (parall\$4 Collimat\$3) same angl \$2	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/08 13:33
S84	1	S82 and (expos\$4 near7 (beam\$4 light radiat\$4 laser ld\$1 laser \$1 ld\$3) Lithography photolithography photosesitive irradiat\$4 radiat\$4 photocur\$4 photosensitiv\$2) near12 (control\$4 tun\$4 adjust \$4 modif\$4 chang\$4 alter\$5 vary\$4 vari\$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/05/08 13:44
S85	1	10/582172	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/12/16 14:11
S87	1	S85 and (cur\$4 same obliquely same blue)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/12/16 14:13
S88	1	(US-6628355-\$). did.	USPAT	OR	OFF	2008/12/16 14:15
S89	0	S88 and (expos\$4 cur \$4) same (obliqu\$5 angl \$4) same (color\$1 colour \$1 blue)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/12/16 14:18
S90	1	S88 and (expos\$4 cur \$4) same (color\$1 colour \$1 blue rgb)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/12/16 14:19
S91	2	"6,535,338".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2008/12/16 15:53
S92	1	(US-6628355-\$). did.	USPAT	OR	OFF	2009/03/25 15:44
S93	1	S92 and (expos\$4 cur \$4) same (color\$1 colour \$1 blue rgb)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2009/03/25 15:44
S95	1	(US-6628355-\$). did.	USPAT	OR	OFF	2009/05/20 15:14
S96	1	S95 and (etch\$5 remov \$4 mask\$4 photo laser \$2 radiat\$5 chemical) same (lens\$2 microlens \$4)	USPAT	OR	OFF	2009/05/20 15:15
S97	1	S95 and (etch\$5 remov \$4 mask\$4 photo laser \$2 uv chemical) same (lens\$2 microlens\$4)	USPAT	OR	OFF	2009/05/20 15:47

9/ 24/ 2009 2:27:21 PM

C:\ Documents and Settings\ kkianni\ My Documents\ EAST\ Workspaces\ 2172b.wsp